

THEORETICAL INVESTIGATION OF DIAMOND FILMS WITH NANOMETER THICKNESS

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Outline of talk

Motivation

- The features of the atomic structure of the *sp*³-hybridized carbon films.
- Electronic and transport properties of the hydrogenated films
- Elastic properties
- Methods of fabrication. Chemically induced phase transition.
- Influence of arrangement of adatoms and attached molecular groups to the structure and properties of *sp*³-hybridized films

Motivation

- Hydrogenation of graphene enlarges its potential application in nanoelectronics. Regular adsorption of hydrogen atoms changes graphene electronic structure and opens the band gap depending upon the distance between hydrogen regions. Total hydrogenation of graphene changes the nature of electronic states due to changing of *sp*² hybridization of C-C bonds to *sp*³ one and opens the dielectric band gap. Such two-dimensional insulator was called as graphane. The theoretical prediction was generally confirmed experimentally by Elias *et. al* [1].
- Graphane is an offspring of graphene along with graphene nanoribbons and carbon nanotubes. The other type of carbon bonding opens a new way for developing of two-dimensional carbon based materials.
- Graphane is the first member in a series of *sp*³ bonded diamond films consist of a number of adjusted oriented layers which display unique physical properties.

Graphene Graphane Diamane

Motivation

Total hydrogenation of graphene changes the nature of electronic states due to changing of *sp*² hybridization of C-C bonds to *sp*³ one. Such two-dimensional insulator was called as graphane and can be considered as a thinnest possible diamond film



But irregular adsorption of the hydrogen atoms doesn't allow to consider graphane as a twodimensional single crystal





Nanotechnology **20** (46): 465704, (2009)

The impact of the irregular adsorption of the hydrogen to the electronic properties of the graphane





H. Gao, L. Wang, J. Zhao, F. Ding, L. Jianping, J. Phys. Chem. C 115, 3236 (2011)

A.K.Singh, B.I. Yakobson, Nano Lett. 9, 1540 (2009)

M.A. Ribas, A.K. Singh, P.B. Sorokin, B.I. Yakobson, Nano Research 4, 1, 143-152 (2011)







L.A. Chernozatonskii, D.G. Kvashnin, P.B. Sorokin, A.G. Kvashnin, J.W. Brüning, J. Phys. Chem. C (in press, 2012) The features of the atomic structure of the *sp*³-hybridized carbon films.

Atomic structure





Electronic and transport properties of the hydrogenated films

Electronic properties of ch1 films



Electronic properties of lonsdaleite-type films



Elastic properties of the hydrogenated films

Elastic properties of ch1 films

	$v_{TA,}(10^3 \text{m/s})$	$v_{LA,} (10^3 \text{m/s})$	Graphane	a)
Graphane	12.0	17.7	E 1500 3 1000	
D(AB)	12.1	17.8		o)
			E 1500	
D(ABC)	12.2	18.0	ABC 3000 3 1500 3 1500 1000	c)
Bulk diamond (experiment)	12.4	18.3		

L.A. Chernozatonskii, P.B. Sorokin et al. JPCC **115**, *1*, 132-136 (2011)

Elastic properties of lonsdaleitetype films

	(10-10) bt1	(-2110) bt2	(0001) ch1
C ₁₁ '	C_{33}	<i>C</i> ₁₁	<i>C</i> ₁₁
C ₁₂ '	C_{13}	C_{13}	C_{12}
C ₁₁ = 1222.5 GPa, C	C ₁₂ = 106.8 GPa, C ₁₃ = 47	7.5 GPa, C ₃₃ = 1326.3 G	Pa, C ₄₄ = 459.4 GPa



Indentation of the films

Strain energy is defined as following:

$$U = \frac{1}{2}\pi\sigma^{2D}\delta^{2} + \frac{E^{2D}q^{3}}{4r^{2}}\delta^{4},$$

where q=1.02 is is a dimensionless constant related to the Poisson's ratio, r is a membrane radius, σ^{2D} is the pretension in the film, E^{2D} is the elastic constant.

Our calculation results was approximated by the 4th order polynomial curve:

$$U=ax^2+bx^4,$$

where coefficients a and b are defined as:

$$a = \frac{\sigma^{2D}\pi}{2}; b = \frac{E^{2D}q^3}{4r^2} \square E^{2D} = \frac{4r^2b}{q^3}$$
$$Y = \frac{E^{2D}}{h}$$

where *h* is a thickness of the film

Indentation of the films





Methods of fabrication. Chemically induced phase transition.

The problem of stability of sp³-hybridized nanostructures



Carbon diamond nanoclusters display graphitization effect due to more energy favorable of graphene against to diamond.

This effect can dramatically impact to the stability of the considered ultrathin diamond films!



Kuznetsov et. al



Barnard, Rev.Adv.Mater.Sci. 2004

Shang et. al, ACS Nano, 2009

Graphite 0.337nm

1nm

The problem of stability of sp³-hybridized films with nanometer thickness

- Diamond two- and three-layered ch1 films...
- Diamond threelayered ch2 films...
- Lonsdaleite twolayered bt1 films...
- Lonsdaleite two-, three-, four- and five-layered ch1 films...

...without passivation are unstable and transform to corresponding multilayered layered graphene



Chemically induced phase transition

 From the other side, multilayered graphene with adsorbed adatoms on the outer surface transforms to sp³-hybridized films without any activation barrier. We call this effect as chemically induced phase transition.



Energy diagram



Phase diagram and dependence of the transition pressure (T=0) upon the ch1 diamond films thickness



Phase diagrams for studied *sp*³hybridized films



Influence of arrangement of adatoms and attached molecular groups to the structure and properties of *sp*³-hybridized films

The evidence of experimental fabrication of *sp*³-hybridized films

The bulk *sp*³-hybridized fluorinated films was already obtained years ago by Japanese scientists in bulk graphite.



On the Structure of Graphite Fluoride

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Dedicated to Professor Paul Hagenmuller on his 65th Birthday

Abstract. The structure of graphite fluoride, $(C_4F)_n$ has been investigated by X-ray analyses, solid state PF-n.m.r., and electron microscopy for well characterized and crystallized samples obtimed from atural graphito et OPG (highly oriented projduc graphitic). On the basic of the present results and structural properties derived from previous works, $(C_2F)_n$ has a layered structure of stage-2 which belongs bezagonal to the system with C_{2h} symmetry. Detailed discussions on the symmetry both for $(C_{2h}$ and $(C_{2F})_h$ have led to possible stacking sequences such unit cell of graphite fluoride should require. The ideal structure of $(C_2F)_n$ is a brazgonal crystal lattice with a =b = 2.5 Å; c = 16.2 Å, and a plausible stacking sequence of AB/B Å/ with I_c (identity period) = 8.09 Å. The largered structure of $(C_{2F})_n$ is of stage -100 Å I_{2F} is of stage -100 Å.







Materials

Room-Temperature Compression-Induced Diamondization of Few-Layer Graphene

Ana P. M. Barboza, Marcos H. D. Guimaraes, Daniel V. P. Massote, Leonardo C. Campos, Newton M. Barbosa Neto, Luiz G. Cancado, Rodrigo G. Lacerda, Helio Chacham, Mario S. C. Mazzoni, and Bernardo R. A. Neves*



The diamondization of fewlayer graphene was observed after the applying of pressure by EPM tip in H_2O atmosphere









ch2

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Evidence of different stacking of multilayered graphene





Lui et al. Nano Lett. 2010 Cong et al. ACS Nano. 2011



AA stacking, Liu et al. Phys. Rev. Lett. 2009

Methodology

$$E_{s} = \frac{E_{tot} - n_{ad}E_{ad} - n_{c}E_{c}}{2S} - \frac{n_{ad}}{2S}\mu_{ad}(T,P)$$

Here, the first part of the difference is the zero-temperature surface energy (per unit area); the last part is the chemical potential of the source of adatoms (or molecular groups) depending on the temperature, *T*, pressure, *P*, and implicitly on the adatoms (molecular groups) concentration

$$\mu_{ad}(T,P) = \Delta H - T\Delta S + kT \ln(x)$$

where ΔH and ΔS are the differences of enthalpy and entropy of the given temperature and the zero one, the values of which were obtained from the reference table, x is mole fraction, amount of the given constituent divided by the total amount of all constituents in a mixture

$$x = \frac{p^{\circ}}{P}$$

Hydrogen



Fluorine



Yellow region: experiment Kita, Y et al. *J. Am. Chem. Soc.* **1979**, *101*, 3832-3841. Watanabe, N. *Solid State Ionics* **1980**, *1*, 87-110

Water and ammonia



Electronic properties

	Band gap, E _g , eV							
Structure	Single layered film	Bi-layered film	Three-layered film					
Hydrogen								
ch1-h	3.4	3.2	2.9					
ch2-h	3.3	2.4	2.2					
Fluorine								
ch1-f	3.1	4.0	4.4					
ch2-f	3.5	4.3	4.4					
Water								
ch1-oh1	4.4	4.1	3.9					
bt1-oh2	4.3	2.6	3.1					
bt1-oh3	3.9	3.1	2.6					
bt2-oh2	4.4	3.5	2.7					
Ammonia								
ch1-nh1	3.1	2.5	2.6					
bt1-nh1	2.6	3.0	2.4					
bt1-nh2	3.3	3.3	3.2					
bt1-nh3	3.9	3.3	3.0					

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